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For Immediate Release

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Eco Agro and Eco Agro International LLC proudly introduce the Nitrogen Conservation Input System (NCIS) for use into the Urea Production Process.

This exciting breakthrough technology is patent pending and based on research developed during the process of acquiring multiple individual patents. NCIS Technology allows for introduction of proven Nitrogen Efficiency additives into Urea production.

"Our latest innovation, "Nitrogen Conservation Input Systems" (NCIS), enables Enhanced Efficiency Fertilizers (EEFs) to be affordable and effective at a lower cost for today's grower. We see NCIS as being a tool that overcomes a significant hurdle toward increased utilization of EEF's worldwide in efforts to improve crop production and yields." said David McKnight, whose team headed the development of NCIS.

In development and testing for over two years, NCIS introduces chemical synergies that allow Nitrogen Efficiency Additives to optimize the conditions for Enhanced Urea Production and performance. Test results have been on-going for over a year and have been very positive.

"By no means is the end of the development in the Urea Production area, there will be next generations of this technology," said Ray Perkins President of Eco Agro. "The options in these innovative discoveries are significant and the delivery system and molecular synergies created can be modified and taken down stream and applied onto Urea also," said Perkins.

Andrew Semple of EAI stated, "These proven Enhanced Efficiency Technologies coupled with an unparalleled low costs of treatment are a major leap toward mass adoption." Semple added "but there are more innovations on the horizon that are game changing and equally as exciting."

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